PHOTOSENSITIVE COMPOSITION AND PHOTOSENSITIVE PLANOGRAPHIC PRINTING PLATE

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Abstract of JP 10097067 (A)

PROBLEM TO BE SOLVED: To obtain a photosensitive planographic printing plate having improve ink receptivity and chemical resistance without deteriorating sensitivity and developability and to obtain a photosensitive compsn. fit for the photosensitive layer of the printing plate. SOLUTION: The objective photosensitive compsn. contains a monomer represented by the formula CH2 =C(R1)-COO[(CH2)n-O-]m R, an oligomer or prepolymer having constituent units formed from the monomer or further contains a high molecular polymer having an unsatd. or satd. group and a phenyl group in a side chain and having a wt. average mol.wt. of >=10,000 and >=80 deg.C glass transition temp. In the formula, R is a substituent such as an unsatd. group, unsubstd. alkyl, hydroxyalkyl or carboxyalkyl, (m) is an integer of >=2, (n) is an integer of >=3 and R1 is H or methyl.; The objective photosensitive planographic printing plate has a photosensitive layer made of the photosensitive compsn.

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